



ICMOVPE XXII

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ICC JEJU, Jeju Island, Korea

Name of Company	LumiGNtech Co.,Ltd	Company Logo
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Exhibitor Introduction	Welcome to LumiGNtech, a specialized manufacturer of advanced compound semiconductor substrates and templates. We provide high-quality Gallium Nitride (GaN) and Aluminum Nitride (AlN) wafers grown via our proprietary, high-throughput HVPE (Hydride Vapor Phase Epitaxy) technology. Our core products include free-standing GaN wafers, AlN templates, and AlGaIn templates. These materials are essential for next-generation applications such as Ultra High Brightness (UHB) LEDs, Micro/Nano LEDs, UVC LEDs, and Power/RF electronics. LumiGNtech stands out with its cost-effective and highly efficient manufacturing process . By utilizing our innovative self-separation technology with an AWC (AlN with Carbon buffer) layer .	
Exhibit Product	GaN wafer, AlN template, Ga2O3 epi wafer, AlN with Carbon buffer template	